

Quantitative analysis of the proximity effect in Nb/Co₆₀Fe₄₀, Nb/Ni, and Nb/Cu₄₀Ni₆₀ bilayers

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(Received 12 January 2005; revised manuscript received 11 April 2005; published 12 July 2005)

We have studied the behavior of the superconducting critical temperature T_c in Nb/Co₆₀Fe₄₀, Nb/Ni, and Nb/Cu₄₀Ni₆₀ bilayers as a function of the thickness of each ferromagnetic metal layer. The T_c 's of three sets of bilayers exhibit nonmonotonic behavior as a function of each ferromagnetic metal thickness. Employing the quantitative analysis based on Usadel formalism of the effect of the exchange energy, we observed that the T_c behavior of Nb/Co₆₀Fe₄₀ bilayers is in good agreement with the theoretical values over the entire range of the data. On the other hand, the T_c 's of Nb/Ni and Nb/Cu₄₀Ni₆₀ bilayers show a higher value in the small thickness regime than the theoretical prediction obtained from the calculation, which matches the dip position and the saturation value of T_c in the large thickness limit. This discrepancy is probably due to the weakened magnetic properties of Ni and Cu₄₀Ni₆₀ when they are thin. We discuss the values of our fitting parameters and their implication for the validity of the current Usadel formalism of the effect of the exchange energy.

DOI: [10.1103/PhysRevB.72.014518](https://doi.org/10.1103/PhysRevB.72.014518)

PACS number(s): 74.45.+c, 74.62.Yb

I. INTRODUCTION

The coexistence of superconductivity and magnetic order has been studied for several decades, and it is well known that ferromagnetism is detrimental to superconductivity. However, the two orders can coexist under special circumstances. Larkin and Ovchinnikov, and Fulde and Ferrell (LOFF) suggested that, in a superconductor containing localized magnetic moments, the superconducting order parameter can survive with a spatial modulation caused by the effect of an exchange field on the Cooper pairs.^{1,2} Experimental observations of this state have not yielded success until recently, because the strength of exchange energy must be within a certain narrow range.³ This experimental difficulty can be avoided when we are dealing with a superconductor(S)/ferromagnetic-metal (F) heterostructure in which the superconductivity is induced in the ferromagnetic region via the proximity effect. In this system, superconductivity can coexist in a thin layer in the ferromagnetic region near the SF boundary. This system offers another way to study the coexistence of superconductivity and magnetism.

The proximity effect between superconductivity and magnetism has been studied for some time. It had been believed that there is a large suppression of the superconducting order parameter at the SF interface due to the strong pair breaking by the ferromagnet via spin-flip scattering and/or spin-rotation at the interface. This strong suppression of the order parameter had often been taken into account by imposing a vanishing boundary condition at the SF interface. In more recent theoretical studies of the proximity effect in SF

heterostructures,⁴⁻⁸ however, it has been pointed out that the T_c of the heterostructure is expected to exhibit an oscillatory behavior as a function of ferromagnetic metal thickness due to the modulation of the order parameter by the exchange energy, much like the LOFF state. In particular, the T_c oscillation in SF superlattices and in SFS trilayers has been ascribed to the π -phase coupling of the altering superconducting layers.^{4,5}

The T_c behavior in SF heterostructure has been investigated experimentally by many groups. Strunk *et al.* studied a T_c behavior in Nb/Gd/Nb triple layer systems.⁹ The authors observed not oscillatory but steplike behavior, which was attributed to the ferromagnetic transition of Gd films of a certain thickness. The T_c oscillation was observed by Jiang *et al.* in Nb/Gd multilayer system, and they ascribed the oscillation to π -phase coupling.¹⁰ Muhge *et al.* observed similar behavior in Fe/Nb/Fe trilayers, but they pointed out that the magnetic dead layer plays a dominant role in the oscillation.¹¹ In Refs. 8,12, nonmonotonic T_c behavior in Nb/CuNi bilayer systems was reported and analyzed in a quantitative way. An oscillatory T_c behavior in Nb/Ni system and its quantitative analysis was reported in Ref. 13. There have been many experimental efforts to confirm T_c oscillation in many kinds of SF heterostructures besides the works mentioned above,¹⁴⁻¹⁸ including the quantitative analyses of nonmonotonic T_c behavior of SF heterostructures that have been performed in Refs. 19 and 20 using the theory by Tagirov.⁷

In this paper, we present our experimental results on T_c behavior in SF bilayer systems with Nb as a superconductor and three kinds of ferromagnetic metal, each having a

different Curie temperature: Nb/Co₆₀Fe₄₀, Nb/Ni, and Nb/Cu₄₀Ni₆₀ bilayers. We also present a quantitative analysis of our data using the Usadel formalism, taking into account only the exchange energy inside the ferromagnetic metals as the pair-breaking mechanism.

II. SAMPLE FABRICATION AND MEASUREMENTS

All the samples were deposited with a multisource dc magnetron sputtering system at ambient temperature using an oxidized Si wafer as the substrate. The thickness of the oxidized layer was 200 nm and the lateral size of the strip-shaped substrates was 2×7 mm². After the chamber was evacuated to 2×10^{-8} Torr, Nb films were deposited using 99.999 % pure argon gas at 4 mTorr. A solid Nb (99.95% pure) target was used as a source and the deposition rate was 0.29 nm/s. To minimize run-by-run scatter in T_c which can be caused by a small difference in the sample preparation conditions, we deposited the Nb layer simultaneously on several samples arranged in a line. The uniformity of the T_{cS} of each Nb sample was measured separately and found to be within 20 mK, and the uniformity of the T_c of each Nb (24 nm)/Co₆₀Fe₄₀(>7 nm) sample was found to be within 30 mK. Then, ferromagnetic layers were deposited *in situ* immediately after Nb deposition, to avoid possible contamination and oxidation of the Nb film surface. To obtain a systematic variation in the thickness of the ferromagnetic layers, we used the natural gradient of the sputtering rate caused when the stage of the substrates is placed in an asymmetric position relative to the center of ferromagnetic target. For the deposition of ferromagnetic layers, 99.9% pure Co₆₀Fe₄₀, 99.98% pure Ni, and 99.95% pure Cu₄₀Ni₆₀ solid targets were used, respectively, as sources. The deposition rates of each ferromagnetic layer were 0.1 nm/s for Co₆₀Fe₄₀, 0.13 nm/s for Ni, and 0.14 nm/s for Cu₄₀Ni₆₀, respectively. As a final step, all the samples were capped with 2 nm of Al to prevent oxidation in the air. The layer thickness was controlled by its deposition time during growth with its deposition rate calibrated using a profilometer. The calibrated thickness of the part of the samples was confirmed by the measurement using transmission electron microscopy and low-angle x-ray diffraction.

The superconducting transition temperatures of the bilayers were measured resistively using a standard dc 4-probe technique with the current magnitudes at 0.1 mA and determined as the temperature at which the resistance of the samples reaches 10% of the normal state resistance at $T = 10$ K.

III. RESULTS AND ANALYSIS

Typical R vs T curves near T_c normalized to the normal state resistance at $T = 10$ K can be seen in Fig. 1, with varying d_{Ni} for $d_{Nb} = 22.5$ nm. All the R vs T curves during the transitions are almost parallel to each other and exhibit sharp transition. These transition curves correspond to T_c 's represented by empty square symbols in Fig. 3(a).

Figure 2 shows the T_c behavior of Nb/Co₆₀Fe₄₀ bilayers as a function of Co₆₀Fe₄₀ thickness d_{CoFe} with fixed thickness

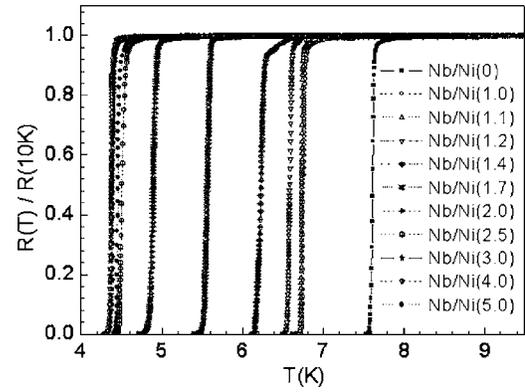


FIG. 1. Normalized $R(T)$ curves of Nb(22.5 nm)/Ni bilayer samples near T_c . The number in parentheses indicates the thickness of Ni of the corresponding sample. The lines are a guide for the eyes. Resistance is normalized by the value in the normal state at $T = 10$ K. The T_c is determined using a 10% criterion, and these T_c 's correspond to the open square symbol in Fig. 3(a).

of Nb, $d_{Nb} = 26$ nm for two different sets of samples. As can be seen in the data, the T_c of the bilayers decreases monotonically from T_{cS} of a single Nb layer with increasing thickness of Co₆₀Fe₄₀ until it reaches about 2 nm, and then increases slightly but definitely to approach a limiting value, resulting in a shallow dip feature of about 100 mK, well above our experimental resolution. We analyzed this data using the method in Refs. 8 and 21 based on the Usadel formalism.²² In this formalism, only the influence of exchange field was included by ignoring the effects of the spin-flip scattering and/or spin-rotation.

To fit our data, we determined the resistivity values of each layer at $T = 10$ K, $\rho_{Nb} = 14.6 \mu\Omega$ cm, $\rho_{CoFe} = 14.8 \mu\Omega$ cm, and superconducting transition temperature of 26 nm thickness single Nb layer, $T_{cS} = 7.94$ K, from separate experiments. The residual resistivity ratio for this Nb single layer is 1.93. The resistivity of Nb film was determined from the resistance value of Nb film deposited on oxidized silicon surface, taking into account the dimension of the sample and the configuration of the contacts for dc 4-probe measurement. The resistivity value and T_{cS} for Nb

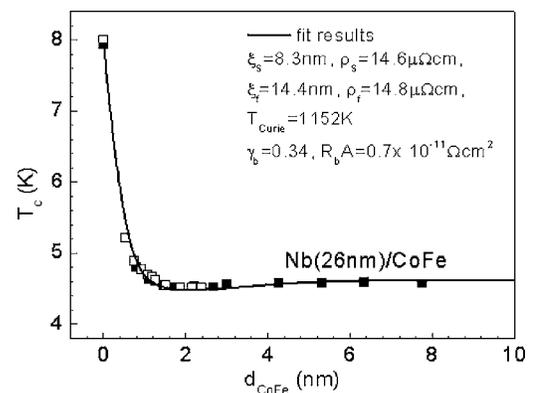


FIG. 2. T_c of Nb(26 nm)/Co₆₀Fe₄₀ bilayers as a function of d_{CoFe} . The different symbols mean two different sets of data. The solid line is a fit result.

film are consistent with the universal behavior of T_{cS} vs ρ_{Nb} reported in Refs. 23 and 24. On the other hand, the resistivity of CoFe film was determined from the resistance value of the 10 nm thick CoFe film deposited on top of a Nb layer, using the parallel resistor model. This is because the resistance value of the thin film varies depending on the layer underneath it. Fixing these values, we obtained the following parameters from the fitting: the dirty limit coherence length of superconductor and ferromagnetic metal $\xi_S = \sqrt{\hbar D_S / 2\pi k_B T_{cS}}$ and $\xi_f = \sqrt{\hbar D_f / 2\pi k_B T_{cS}}$, the parameter which represents interface resistance between superconductor and ferromagnetic metal $\gamma_b \equiv R_b A / \rho_f \xi_f$, where $R_b A$ is a resistance at SF boundary, and the exchange energy in ferromagnetic metal E_{ex} . E_{ex} determines the dip position, which is the thickness of the magnetic film where the dip of the T_c vs d_{CoFe} arises. On the other hand, the parameter which has the largest influence on the saturated T_c value is γ_b . The best result was obtained, yielding $\xi_S \approx 8.3$ nm, $\xi_f \approx 14.4$ nm, $\gamma_b \approx 0.34$, and $E_{ex} \approx 99.4$ meV. The solid line in Fig. 2 represents this result. The line exhibits excellent agreement with the data.

We estimated the mean free path of the Nb film from the coherence length, ξ_S . From the definition in the dirty limit $\xi_S = \sqrt{\hbar D_S / 2\pi k_B T_{cS}}$ and the diffusion constant $D_S = \frac{1}{3} v_F l_{Nb}$, we obtained the mean free path $l_{Nb} \approx 2.4$ nm when a Fermi velocity of $v_F = 0.56 \times 10^6$ m/s (Ref. 25) was inserted. From this value of the mean free path, we obtained $(\rho)_{Nb} = 3.56 \times 10^{-16} \Omega \text{ m}^2$, which is comparable to the value in Ref. 26. The interface resistance at the SF boundary estimated from γ_b is to be $R_b A = 0.6 \times 10^{-11} \mu\Omega \text{ cm}^2$, which can be understood as a comparable value to the intrinsic resistance of the interface between two metals.²⁷ The exchange energy in the LOFF picture is supposed to be the exchange splitting of the conduction band of a ferromagnetic material, the sd exchange interaction between the localized spins of d electrons and the itinerant s electrons. The exchange energy determined from our fit is close to its Curie temperature, T_{Curie} , about 1200 K, via the relation $E_{ex} = k_B T_{Curie}$, as was found for $\text{Cu}_{43}\text{Ni}_{57}$ in Ref. 8. Even for the Nb/Ni and Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ case, the exchange energies found from the dip position of the T_c data were all very close to their Curie temperatures, well below the theoretically and experimentally predicted exchange energy among the localized d electrons.²⁸ This may point to the fact that the mechanism that breaks the superconducting pairs at the SF interface is the exchange energy between the itinerant s electrons and the localized spins of d electrons. We conclude that the fitting yields parameters in a reasonable range, and the T_c behavior of the Nb/ $\text{Co}_{60}\text{Fe}_{40}$ bilayers is quantitatively consistent with the theory based on the Usadel formalism.

The nonmonotonic T_c behavior is reproduced when we use Ni and $\text{Cu}_{40}\text{Ni}_{60}$ as a ferromagnetic metal instead of $\text{Co}_{60}\text{Fe}_{40}$, with a fixed $d_{Nb} = 22.5$ nm, although there is some difference in several aspects. Figure 3(a) shows the T_c behavior of Nb/Ni bilayers as a function of Ni thickness for three different series of samples. As can be seen in Fig. 3(a), the T_c 's of Nb/Ni bilayers show comparatively slow decrease with increasing Ni thickness d_{Ni} until reaches ~ 2 nm and then decreases rapidly until the dip position, $d_{Ni} \sim 3$ nm, is reached. Then, T_c 's increase slightly to the limiting value, resulting in a dip feature of about 120 mK. The T_c

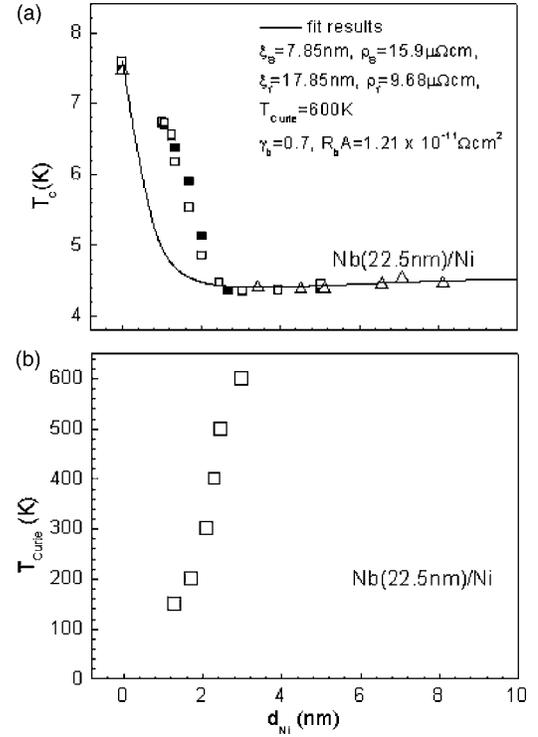


FIG. 3. (a) T_c of Nb(22.5 nm)/Ni bilayers as a function of d_{Ni} . The different symbols mean three different sets of data. The solid line is a fit result. (b) The Curie temperature necessary to fit our data as a function of d_{Ni} .

behavior of Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayers for two series of samples is shown in Fig. 4(a). The shallow dip feature of about 60 mK is observed where the $\text{Cu}_{40}\text{Ni}_{60}$ thickness $d_{\text{CuNi}} \sim 4$ nm, and the slow decrease in T_c below the dip position can again be seen in this data.

The T_c behavior of Nb/Ni bilayers as a function of Ni thickness cannot be fitted with fixed parameters over the entire range of ferromagnetic metal thickness, especially where the thicknesses of ferromagnetic metal are small. The same situation arises in Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayers as well.

For the analysis, we estimated the superconducting coherence length in the S layer from parallelism to the Nb/ $\text{Co}_{60}\text{Fe}_{40}$ bilayer case, considering the difference in resistivity of Nb films due to different thicknesses. Fixing this value and the parameters determined from other experiments, $\rho_{Nb} = 15.9 \mu\Omega \text{ cm}$, $\rho_{\text{Ni}(\text{CuNi})} = 9.68(24.4) \mu\Omega \text{ cm}$, and T_{cS} for each case, we calculated the T_c of each bilayer using the method mentioned in the Nb/ $\text{Co}_{60}\text{Fe}_{40}$ bilayers case, attempting to find a best result which fits the dip position and saturation value of T_c . In the calculation, the values of ξ_f , γ_b , and E_{ex} were adjusted to obtain the best result, and each of these results is represented by the solid lines in Fig. 3(a) and Fig. 4(a).

The parameters yielding the lines in Fig. 3(a) and Fig. 4(a) are as follows: $\xi_f = 17.85$ nm, $\gamma_b = 0.7$, and $E_{ex} \approx 51.8$ meV for Nb/Ni bilayers and $\xi_f = 8.8$ nm, $\gamma_b = 0.57$, and $E_{ex} \approx 14.7$ meV for Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayers, respectively. These parameters are summarized in Table I. The corresponding interface resistance at the SF boundaries $R_b A \sim 1.2 \times 10^{-11} \mu\Omega \text{ cm}^2$, which is almost same in both cases,

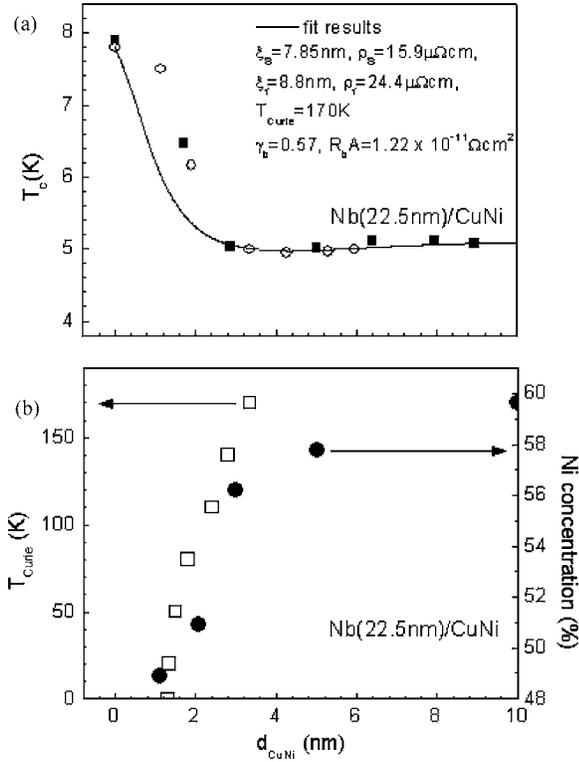


FIG. 4. (a) T_c of Nb(22.5 nm)/Cu₄₀Ni₆₀ bilayers as a function of d_{CuNi} . The different symbols mean two different sets of data. (b) Empty square symbols represent the Curie temperature necessary to fit our data (left axis) and solid circle symbols represent the Ni content in Cu₄₀Ni₆₀ layers on Nb24nm as a function of d_{CuNi} measured using XPS (right axis).

is about twice as large as that of the Nb/Co₆₀Fe₄₀ interface. We can compare the values of exchange energy for Co₆₀Fe₄₀, Ni, and Cu₄₀Ni₆₀ obtained from the fits. Interestingly, the three exchange energy values are all very consistent with their known Curie temperature values.²⁹

In addition, our fitting parameters can be compared with previous results by other groups.^{8,13} For Nb/Ni bilayers, the value for superconducting coherence length ξ_S for our bilayers is larger than that obtained for the Nb/Ni bilayer in Ref. 13, and the dip position for our case is as twice as larger than that in the same reference. This might be due to the difference in the Nb and Ni film properties. On the other hand, the difference in our ξ_S value from that in Ref. 8 is small, and the dip position of our Nb/Cu₄₀Ni₆₀ bilayer seems consistent with that of Ref. 8 obtained for Nb/Cu₄₃Ni₅₇ bilayers when

considering the difference in the Curie temperature of CuNi alloys caused by the relative composition of Cu and Ni.

Although the dip and the saturation values of our T_c data of Nb/Ni and Nb/Cu₄₀Ni₆₀ bilayers can be fit, the fitting results show a lower T_c value than the data in both cases when the ferromagnetic metal thickness is small. No combination generates a result which fits the data for the entire range of ferromagnetic thickness. This discrepancy between the data and the fitting results can be explained by the suppression of magnetism for thin ferromagnetic films because lower values for the exchange energy increases the T_c value of *SF* bilayers. The suppression of magnetism was reported in the references in which the proximity effect in *SF* multilayers with Nb as the superconductor and Gd, Fe, and Ni as the ferromagnetic metals was investigated.^{9–11,15} The reason for the suppression was ascribed to the decrease of the number of nearest neighbors due to the finite size and inhomogeneity of thin films,^{9,10,15} and to the alloying effects at the interface.¹¹ In particular, the superconducting transition temperature and saturation magnetization M_s of Nb/Ni multilayers was studied for a very small ($d_{\text{Ni}} \leq 2$ nm) Ni thickness region in Ref. 15. In this reference, the M_s was almost zero when $d_{\text{Ni}} \leq 1.2$ nm, and the T_c of the multilayers showed a slow decrease, which was similar to that of our Nb/Ni bilayers in the same d_{Ni} range. After this thickness, the M_s from the Ni layers started to increase and the T_c of the multilayers approached zero. The disappearance of superconductivity in this reference was, however, due to the small thickness of Nb. In our case, because we were dealing with a single ferromagnetic layer instead of multiple layers, the measurement of magnetism in the thin film range was not successful due to insufficient magnetic signal for a SQUID magnetometer. However, considering the similarity in T_c behavior between our data and Ref. 15, the suppression of magnetism is highly likely. Figure 3(b) shows the necessary Curie temperature estimated via the relation $E_{ex} = k_B T_{\text{Curie}}$ to fit our data in the small Ni thickness limit. In estimating these values, all other parameters remained the same as the fit results represented by the solid line in Fig. 3(a). Its behavior as a function of Ni thickness is similar to that in Ref. 10, even though a different ferromagnetic material was used.

In our experiment, the roughness of the thin ferromagnetic layers was so small that we did not expect suppression of magnetism due to film inhomogeneity. According to the measurement by using atomic force microscope (AFM), the surface rms roughness of a single Nb layer was 0.155 nm, and the rms roughness values of 0.5- and 1 nm thick ferromagnetic films on 24 nm Nb films did not increase for all

TABLE I. Summary of the parameters and the data of the three sets of bilayers.

Structure	ξ_S (nm)	ρ_S ($\mu\Omega$ cm)	ρ_f ($\mu\Omega$ cm)	γ_b	E_{ex} (meV)	rms roughness (nm)		
						$d_f =$ 0 nm	$d_f =$ 0.5 nm	$d_f =$ 0 nm
Nb/Co ₆₀ Fe ₄₀	8.3	14.6	14.8	0.34	99.4		0.158	0.157
Nb/Ni	7.85	15.9	9.68	0.7	51.8	0.155	0.166	0.161
Nb/Cu ₄₀ Ni ₆₀	7.85	15.9	24.4	0.57	14.7		0.15	0.156

three sets of bilayers, as can be seen in Table I.

The alloying at the interface is a possible candidate for the suppression, which will inevitably lead to a large γ_b . However, because the relatively lower value of γ_b derived from the T_c values of each curves at large thickness of ferromagnetic metals indicates little alloying, we suggest a different explanation; structural disorder in ferromagnetic material can lower its magnetism. The difference in crystal structure between Nb and ferromagnetic metals can cause the structural disorder in small thickness regions. The $\text{Co}_{60}\text{Fe}_{40}$ layer, which is mechanically harder than Cu or Ni, may have fewer structural disorders than the softer Cu or Ni layers. Smaller γ_b values in Nb/ $\text{Co}_{60}\text{Fe}_{40}$ bilayers can be regarded to reflect this assumption.

In addition to the reasons mentioned above, there is another origin for a higher T_c for Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayers in small thickness regions. The Curie temperature of Cu and Ni alloys varies with their relative composition. Ferromagnetism is known to appear when the Ni content is over $\sim 46\%$, and to improve with increasing Ni content.³⁰ In our Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayers, the Ni content of the $\text{Cu}_{40}\text{Ni}_{60}$ layer decreases from 60% to 50% with decreasing the Ni thickness, as can be seen in Fig. 4(b). These x-ray photoemission spectroscopy data were obtained using a ThermoVG (UK) Sigma Probe in ultrahigh vacuum (2×10^{-9} Torr) condition, with monochromatic Al K_{α} x-ray source. This compositional change, probably due to better wetting of Cu than Ni on Nb, causes a decrease in exchange energy. And, as a result, a decrease in the suppression of T_c leads to the higher T_c value of the bilayer. In Fig. 4(b), the necessary Curie temperature to fit the data is also shown.

In addition, the resistivity of this alloy also varies with the relative composition of Cu and Ni.³¹ It has its highest value when the relative composition is $\sim 50:50$. The flux of Cooper pairs penetrating into $\text{Cu}_{40}\text{Ni}_{60}$ decreases when the resistivity of the layer increases, resulting in a smaller decrease in T_c . The T_c of Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayer samples with the smallest thickness of $\text{Cu}_{40}\text{Ni}_{60}$ ($d_{\text{CuNi}}=1.13$ nm) cannot be obtained even with zero exchange energy. Thus, we must include the

increase of resistivity due to the compositional change.

The spin-flip scattering is another mechanism which can lead to pair breaking in the proximity effect of SF heterostructures. In Ref. 17, in which Fe/Cu multilayers were studied, the nonmonotonic T_c behavior was observed; the minimum T_c was observed when Fe thickness was around 0.5 nm. In this reference, the magnetic transition of the Fe layer from fcc γ -Fe to bcc α -Fe at the similar Fe thickness for T_c minimum was reported. It was suggested that, in bcc α -Fe with larger exchange energy than fcc γ -Fe, the spin-flip scattering is hindered by correlations between the magnetic atoms, resulting in the increase of T_c .

Although we have completely ignored the spin-flip scattering or spin-rotation caused by strong interaction with the localized magnetic moment at the interface, all our T_c data of three sets of bilayers can be fit reasonably well with the Usadel formalism of the effect of the exchange energy. Furthermore, the reasonable scaling of the dip position with the Curie temperature strengthens the exchange energy-based Usadel picture. The only discrepancy with the Usadel model was the weakened magnetism at the interface for the Ni and the $\text{Cu}_{40}\text{Ni}_{60}$ cases.

In summary, we have presented the nonmonotonic T_c behavior in three different sets of SF bilayers. The nonmonotonic T_c behaviors were observed in several sets of samples, even though there were small differences in detailed parameters. The difference between the minimum T_c and the saturation value of T_c , ranging from 60 to 120 mK depending on the ferromagnetic materials, was certainly larger than our experimental error. From the analysis using the theory based on the Usadel formalism of the effect of the exchange energy, we observed a good agreement between our data and the theory. In Nb/Ni and Nb/ $\text{Cu}_{40}\text{Ni}_{60}$ bilayers, however, we have found evidences for a thin, magnetically weakened layer which is responsible for a slow initial decrease in the T_c of the bilayers, possibly due to structural disorder and/or composition change.

This work is partially supported by KOSEF through CSCMR and by MOST through National Program for Tera-Level Nanodevice.

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¹A. Larkin and Y. Ovchinnikov, Sov. Phys. JETP **20**, 762 (1965).

²P. Fulde and R. A. Ferrell, Phys. Rev. **135**, A550 (1964).

³M. A. Clogston, Phys. Rev. Lett. **9**, 266 (1962).

⁴A. I. Buzdin and M. Yu. Kupriyanov, JETP Lett. **52**, 487 (1990).

⁵Z. Radovic, M. Ledvij, L. Dobrosavljevi-Gruji, A. I. Buzdin, and J. R. Clem, Phys. Rev. B **44**, 759 (1991).

⁶E. A. Demler, G. B. Arnold, and M. R. Beasley, Phys. Rev. B **55**, 15174 (1997).

⁷L. R. Tagirov, Physica C **307**, 145 (1998).

⁸Y. V. Fominov, N. M. Chitchev, and A. A. Golubov, Phys. Rev. B **66**, 014507 (2002).

⁹C. Strunk, C. Sürgers, U. Paschen, and H. v. Löhneysen, Phys. Rev. B **49**, 4053 (1994).

¹⁰J. S. Jiang, D. Davidovi, D. H. Reich, and C. L. Chien, Phys. Rev. Lett. **74**, 314 (1995).

¹¹T. Mühge, N. N. Garif'yanov, Yu. V. Goryunov, G. G. Khaliullin, L. R. Tagirov, K. Westerholt, I. A. Garifullin, and H. Zabel, Phys. Rev. Lett. **77**, 1857 (1996).

¹²V. V. Ryazanov, V. A. Oboznov, A. S. Prokof'ef, and S. V. Dubonos, JETP Lett. **77**, 39 (2003).

¹³A. S. Sidorenko, V. I. Zdravkov, A. A. Prepelitsa, C. Helbig, Y. Luo, S. Gsell, M. Schreck, S. Klimm, S. Horn, L. R. Tagirov, and R. Tidecks, Ann. Phys. **12**, 37 (2003).

¹⁴L. V. Mercaldo, C. Attanasio, C. Coccorese, L. Maritato, S. L. Prischepa, and M. Salvato, Phys. Rev. B **53**, 14040 (1996).

¹⁵J. E. Mattson, R. M. Osgood III, C. D. Potter, C. H. Sowers, and S. D. Bader, J. Vac. Sci. Technol. A **15**, 1774 (1997).

¹⁶J. Aarts, J. M. E. Geers, E. Brück, A. A. Golubov, and R. Coehoorn, Phys. Rev. B **56**, 2779 (1997).

¹⁷M. Velez, M. C. Cyrille, S. Kim, J. L. Vicent, and Ivan K. Schuller, Phys. Rev. B **59**, 14659 (1999).

- ¹⁸O. Bourgeois and R. C. Dynes, Phys. Rev. B **65**, 144503 (2002).
- ¹⁹L. Lazar, K. Westerholt, H. Zabel, L. R. Tagirov, Yu. V. Goryunov, N. N. Garif'yanov, and I. A. Garifullin, Phys. Rev. B **61**, 3711 (2000).
- ²⁰I. A. Garifullin, D. A. Tikhonov, N. N. Garif'yanov, L. Lazar, Yu. V. Goryunov, S. Ya. Khlebnikov, L. R. Tagirov, K. Westerholt, and H. Zabel, Phys. Rev. B **66**, 020505(R) (2002).
- ²¹H. Doh and H. Y. Choi, cond-mat/0407149 (unpublished).
- ²²K. D. Usadel, Phys. Rev. Lett. **25**, 507 (1970).
- ²³S. I. Park and T. H. Geballe, Physica B & C **135**, 108 (1985).
- ²⁴C. Stürgers, C. Strunk, and H. v. Löhneysen, Thin Solid Films **239**, 51 (1994).
- ²⁵H. W. Weber, E. Seidl, C. Laa, E. Schachinger, M. Prohammer, A. Junod, and D. Eckert, Phys. Rev. B **44**, 7585 (1991).
- ²⁶R. A. French, Cryogenics **8**, 301 (1968).
- ²⁷S. Datta, *Electronic Transport in Mesoscopic Systems* (Cambridge University Press, Cambridge, 1996).
- ²⁸D. E. Eastman, F. J. Himpsel, and J. A. Knapp, Phys. Rev. Lett. **44**, 95 (1980).
- ²⁹B. D. Cullity, *Introduction to Magnetic Materials* (Addison-Wesley, Reading, MA, 1972).
- ³⁰T. J. Hicks, B. Rainford, J. S. Kouvel, G. G. Low, and J. B. Comly, Phys. Rev. Lett. **22**, 531 (1969).
- ³¹B. Svensson, Ann. Phys. **25**, 263 (1936).